

## Certificate of Mailing Under 37 CFR 1.8

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⊯ Bromaghim

June 15, 2005

CUSTOMER NO. 36257

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Anatoly FABRIKANT et al.

Title:

System for Scatterometric Measurements and Applications

Application No.:

09/671,715

Filing Date:

September 27, 2000

Examiner:

Zandra V. SMITH

Group Art Unit:

2877

Docket No.:

TNCR.188US0

Conf. No.:

6087

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98, Applicant(s) call(s) the documents listed on the enclosed Form PTO-1449 to the Examiner's attention in this patent application.

According to 37 C.F.R. 1.98(2)(ii), copies of the U.S. Patents and U.S. Published Patent Applications documents are not required and are therefore not enclosed. Copies of the listed foreign patent documents or Other Art are enclosed.

Attorney Docket No.: TNCR.188US0

Application No. 09/671,715

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Citation of these documents shall not be construed as (1) an admission that the documents are prior art with respect to the invention or inventions claimed in this application, (2) a representation that a search has been made (other than as indicated by any cited document), or (3) an admission that the cited information is, or is considered to be, material to patentability as defined in § 1.56(b).

This information disclosure statement is submitted under 37 C.F.R. § 1.97(b) and consequently no fee should be required. The Commissioner is authorized, however, to charge any fee that may be required, or to credit any overpayment, against Deposit Account No. 502664. This form is being submitted in duplicate.

Respectfully submitted,

-June 15, 2005

Date

Reg. No. 29,545

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U.S. Depa	rtment	of Commerce, Patent	and Trademark	Atty. Docket No.			Application No.				
INFORMATION DISCLOSURE STATEMENT BY				TNCR.188US0 (formerly M-10699 US)			09/671,715				
		APPLICANT		Applicant(s)			Conf. No.				
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TRADE	A1	Number 6,768,967 B2	Date 07/27/2004	Name JOHNSON et al.	Class 702	Subclass 179	If Appro	priate			
	A2	6,097,488	08/01/2000	GREK et al.	356	364	<del> </del>				
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*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate				
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	D1	US Provisional Appln. No. 60/224,451, filed 08/10/2000, to STANKE et al., cited in USP 6,768,967, 28 pgs.									
•	D2	LI, "Formulation and Comparison of Two Recursive Matrix Algorithms for Modeling Layered Diffraction Gratings", J. Opt. Soc. Am. A/Vol. 13, No. 5 / May 1996, pp. 1024-1035.									
-	D3 International Search Report from corresponding PCT Appln. PCT/US01/30063, dated 12/21/01, 4 p										
	D4	Written Opinion from corresponding PCT Appln. PCT/US01/30063, dated 9/18/2002, 5 pages.									
	D5 International Preliminary Examination Report from corresponding PCT Appln. PCT/US01/30063, dated 1/16/2003, 6 pages.										
	D6	Patent Search condu	cted on August 1,	2000 (53 pages).							
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U.S. Department of Commerce, Patent and Trademark				Atty. Docket No.			Application No.					
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				Applicant(s)			Conf. No.					
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	D2	BLAYO et al., "Ult	raviolet-Visible E	llipsometry for Process	Control Duri	ng the Etching	of Submicror	neter				
		BLAYO et al., "Ultraviolet-Visible Ellipsometry for Process Control During the Etching of Submicrometer Features" J. Opt. Soc. Am. A., vol. 12, No. 3, Mar. 1995, pp. 591-599.										
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	D9	MOHARAM, "Coupled-Wave Analysis of Two-Dimensional Dielectric Gratings", SPIE: Vol. 883, Holographic Optics: Design and Applications (1988), pp. 8-11.										
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	D11	MOHARAM et al., "Formulation for Stable and Efficient Implementation of the Rigorous Coupled-Wave Analysis of Binary Gratings", J. Opt. Soc. Am. A./Vol. 12, No. 5, May 1995, pp. 1068-1076.										
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.												